

***Interactive comment on “Chamber simulation of photooxidation of dimethyl sulfide and isoprene in the presence of NO<sub>x</sub>” by T. Chen and M. Jang***

**Anonymous Referee #3**

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The comment was uploaded in the form of a supplement:  
<http://www.atmos-chem-phys-discuss.net/12/C6433/2012/acpd-12-C6433-2012-supplement.pdf>

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